

# Argon Gas For Laboratories Refrigeration Lighting Semiconductors Applications

## **Basic Information**

. Place of Origin: China Brand Name: CMC COA · Certification: Model Number: Ar 1kg • Minimum Order Quantity: • Price: US \$15/kg Cylinder/Tank · Packaging Details: • Delivery Time: 15 days Payment Terms: L/C, T/T . Supply Ability: 5000kg/month



# **Product Specification**

Product Name: Argon Gas
Cylinder Standard: DOT/ISO/GB
Boiling Point: -185.7 C
Melting Point: -189.2 C
Density: 1.784 Kg/M³
Transport Package: Sea Transportation
Specification: 10L 40L 47L 50L 200L

• Trademark: CMC

Origin: Suzhou, China
 HS Code: 2804290000
 Supply Ability: 2000piece/Month
 CAS No.: 7440-37-1
 Formula: Ar
 EINECS: 231-147-0

Constituent: Industrial Pure Air



**Argon Gas** 

## **Product Description**

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Argon gas is a colorless, odorless, and inert gas. It belongs to the noble gases group on the periodic table, along with helium, neon, krypton, xenon, and radon. Argon is the third most abundant gas in the Earth's atmosphere, making up about 0.93% of the air we breathe.

Argon is obtained through the fractional distillation of liquid air. It is commonly used in various applications due to its inertness and low reactivity. Some common uses of argon gas include:

Welding: Argon is often used as a shielding gas in welding processes, such as TIG (Tungsten Inert Gas) and MIG (Metal Inert Gas) welding, to protect the weld area from atmospheric contamination.

Lighting: Argon is used in various lighting applications, such as fluorescent tubes, high-intensity discharge lamps, and plasma displays. It helps create a stable and uniform glow when electrically excited.

Laboratories: Argon is used as a carrier gas in gas chromatography and as an inert atmosphere in various laboratory processes to prevent unwanted chemical reactions.

Refrigeration: Argon is sometimes used as a refrigerant in certain specialized applications, especially in cases where other refrigerants may have safety concerns or environmental issues.

Laser Technology: Argon lasers, which utilize ionized argon gas to produce coherent light, are used in scientific research, medical procedures, and laser light shows.

These are just a few examples of the many applications of argon gas. Its inertness and unique properties make it useful in various industries and scientific fields.

#### Basic Info.

Model NO. Ar Content Content: 28tons

Industrial Grade Industrial Grade Tank Car 26m<sup>3</sup>

Purity 100.00% Transport Package Sea Transportation

Specification Tank Car: 26m3; Content: : 28tons Trademark CMC

Origin suzhou Production Capacity 5000 piece/Month

#### **Product Parameters**

Specification Tank Car:26m³ Content: 28tons

1. used as a protective gas for the production of high purity silicon and germanium crystals in the semiconductor industry;
2. used as inert gas for system cleaning, shielding and pressurization;
3. Be applied in chemical vapor deposition, sputtering, annealing and other processes.
4. used as chromatographic carrier gas, and can also be used as a dilution gas of gas mixture in large-scale integrated circuits.

### **Detailed Photo**



## **Company Profile**



Shanghai Kemike Chemical Co., Ltd is staffed by trained personnel, combine many years experience in Gas industry .We supply cylinder gas, electronic gas, etc., and the gas holder, panel, valves and fittings and other equipment, parts and engineering services to our customers in China and worldwide; The products are involved in various industrial fields, such as semiconductor chip, solar cell, LED, TFT-LCD, optical fiber, glass, laser, medicine, etc., Our mission is to partner with our

global customers to provide support, solutions and quality products that are innovative, reliable, and safe. Our products mainly include: H2, O2, N2, Ar, CO2, propane, acetylene, helium, laser mixed gas, SiH4, Sih2cl2, SiHCL3, SiCL4, NH3, CF4, NF3, SF6, HCL, N2O, doping mixed gas (TMB, PH3, B2H6) and other electronic gases.

SiCI4 NH3 CH3F SiH4 H<sub>2</sub>S WF6 F6+CI2 NH3 Kr HCI+Ne C3F8 C3F8 **TEOS** CH4 PH<sub>3</sub> SF<sub>6</sub> C2 4MS TMB+H2 SiH<sub>2</sub> CF4 C4F8

SiF4 **C3H8** CI2 C3H6 DCE BBr3

POCI3 N<sub>2</sub> **SO2** D+B CO+NO

SiHCI3 CH2F2 **C2H4** C2H2 HBr COS Ar+O2 HF AsH3

Xe+NO GeH4 H2Se GeCI4 **TMAI** DEZn **C2H6 B2H6** DMZn





BCI3

D2

CO<sub>2</sub>



He +As

Ge+Se

Shanghai Kemike Chemical Co.,Ltd